

U.S. Serial No. 10/594,868

Attorney Docket No: 14055.0004FPWO

Agenda for Examiner Interview on March 16, 2012 at 11 am EST

Participants: Eric DeMaster (Reg. No. 55,107) and Examiner Joel Horning

Claims 1-7 and 9-13 rejected under 35 U.S.C. § 103(a) as being unpatentable over Haas (Surface and Coatings Technology, 1999, 111:72-79) in view of Linden (W003/066933) in view of Goodwin (W003/086031).

- 1) Plasma vapour deposition process for plasma coating of ORMOCER® layers is completely different from coating a thin film with ORMOCER® lacquer using conventional wet coating techniques (e.g., dip-coating, spray coating, spincoating) followed by curing as disclosed in Haas.
- 2) Plasma vapour deposition process is completely different from chemical vapour deposition process disclosed in Linden. The process in Linden is intrinsically different from a plasma process in that a chemical vapour phase is produced rather than dispersion of a species in a plasma.
- 3) ORMOCER® composition disclosed in Hass is prepolymerized to form oligomers which do not lend themselves to evaporation. Therefore, the ORMOCER® composition in Haas is not suitable for/compatible with the vapour deposition process in Linden or Goodwin.